

Electromagnetic Design of Diffractive, Micro Cavity, and Photonic Band Gap Devices

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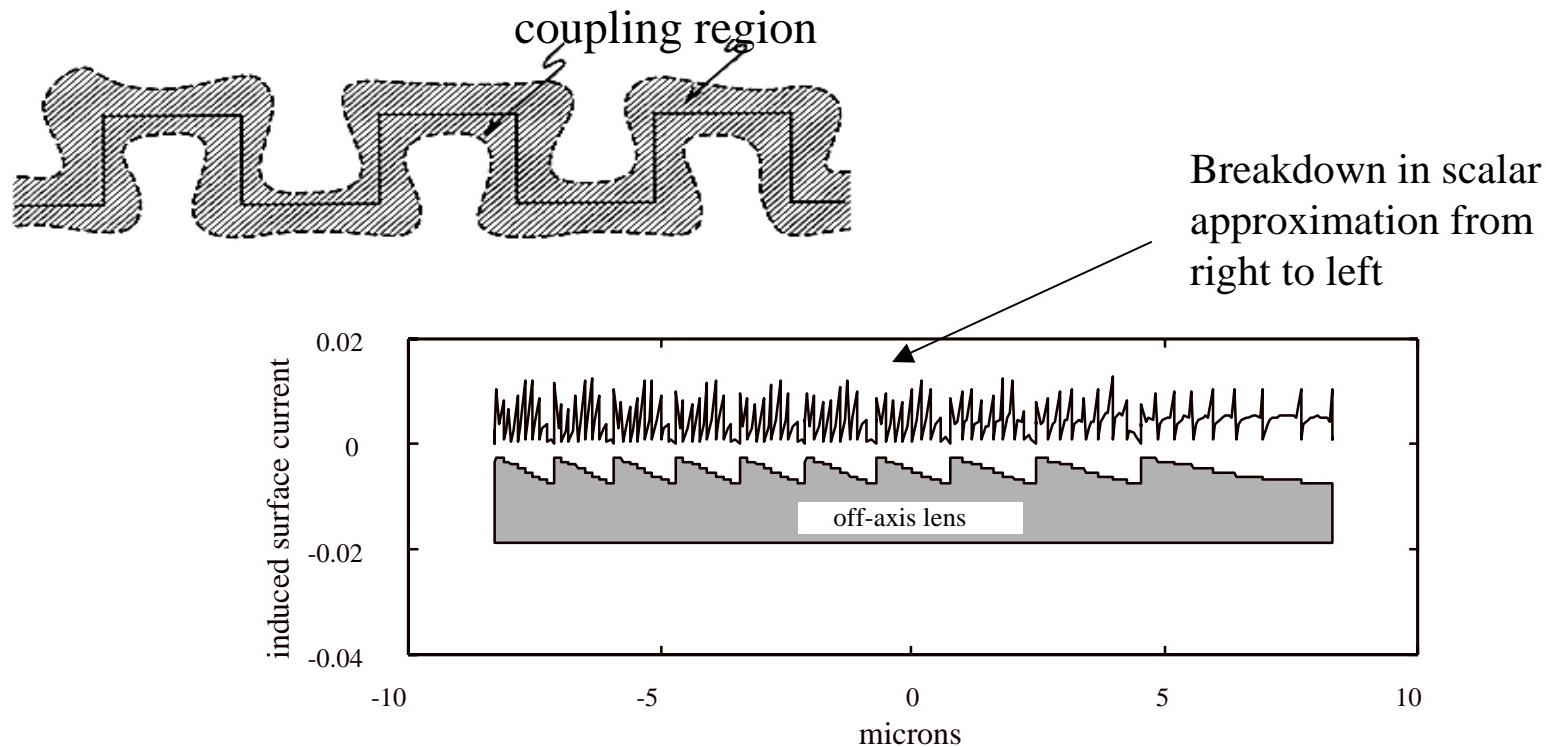
Outline

- Electromagnetic Analysis and Design of Micro-Photonic Devices
- Applications for WDM
 - Embedded spectrometer
 - Photonic band gap filtering
- Diffractive Optic Design for On-Axis Spectroscopy
 - $f/\#$ dependence chromatic dispersion
 - Wavelet based multiresolution optimization
 - Fabrication of meso-scopic grayscale DOEs
- Photonic Band Gap Filters
 - Band Gap Design for finite length PBGs
 - Cavity arrays for WDM
 - Active semiconductor modeling



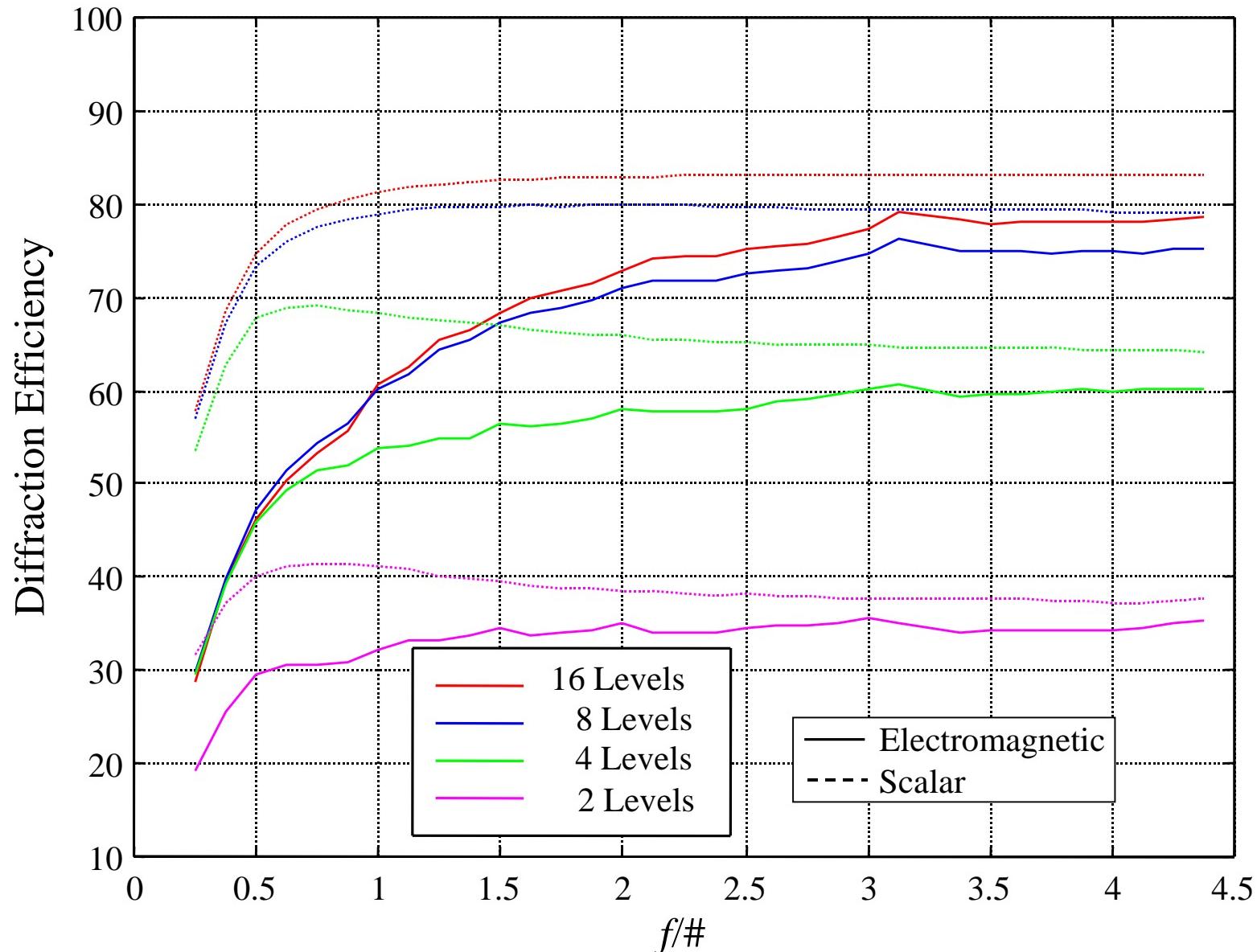
Why Electromagnetic Models Are Necessary

- As the scale of photonic devices approach the wavelength of operation boundary coupling effects significantly influence the EM fields on the boundary.
- This effect must be fully accounted for in the solution to the boundary value problem.
- This precludes the use of scalar and various other approximate methods.





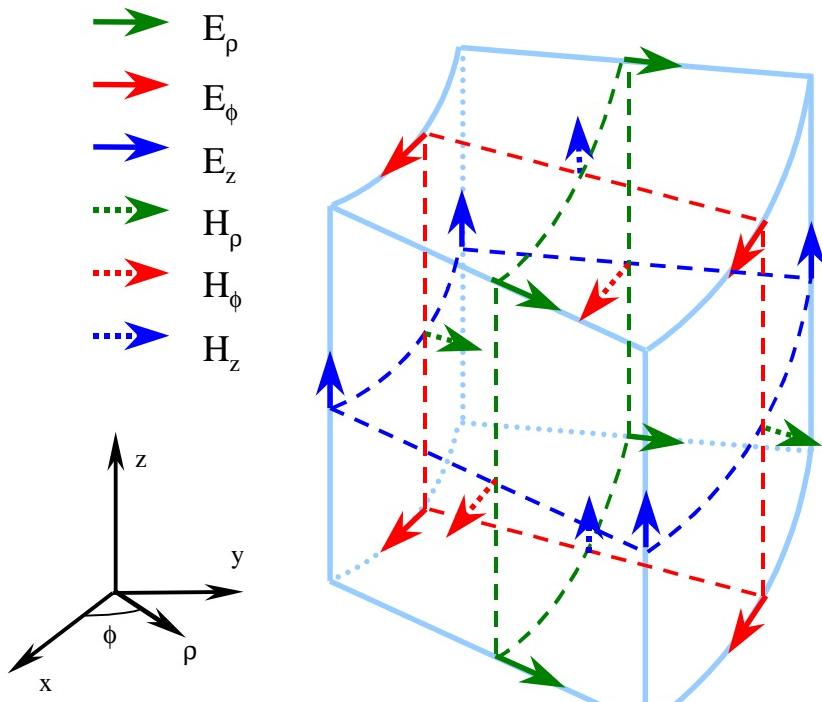
3D Diffractive Lens Analysis Results



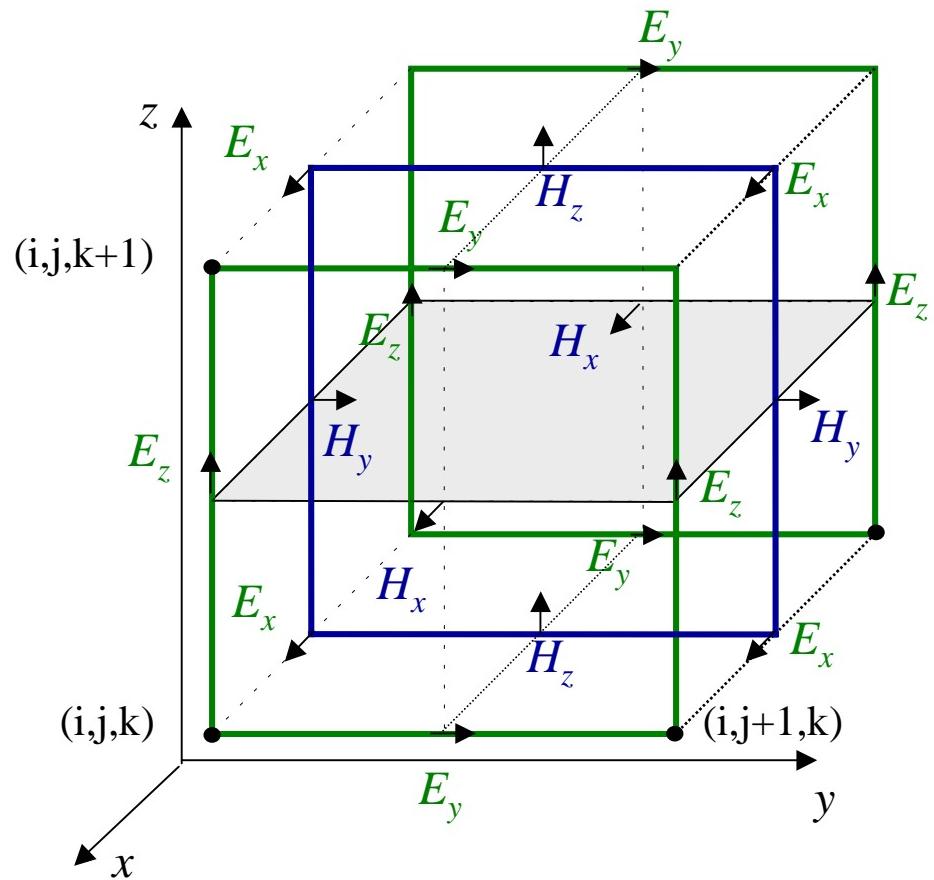


Computational Lattices In Three-Dimensions

BOR FDTD Unit Cell

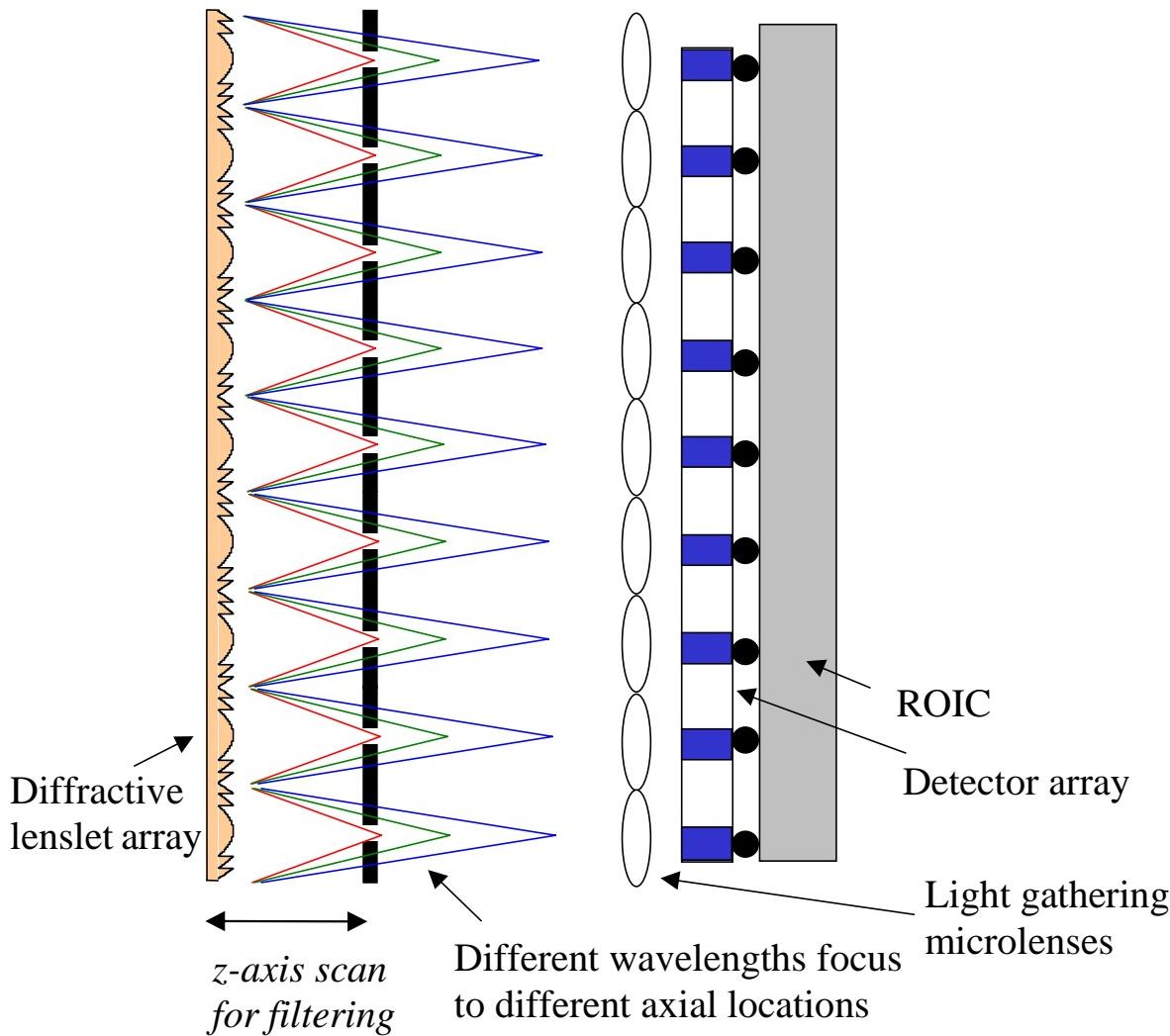


Full 3D FDTD





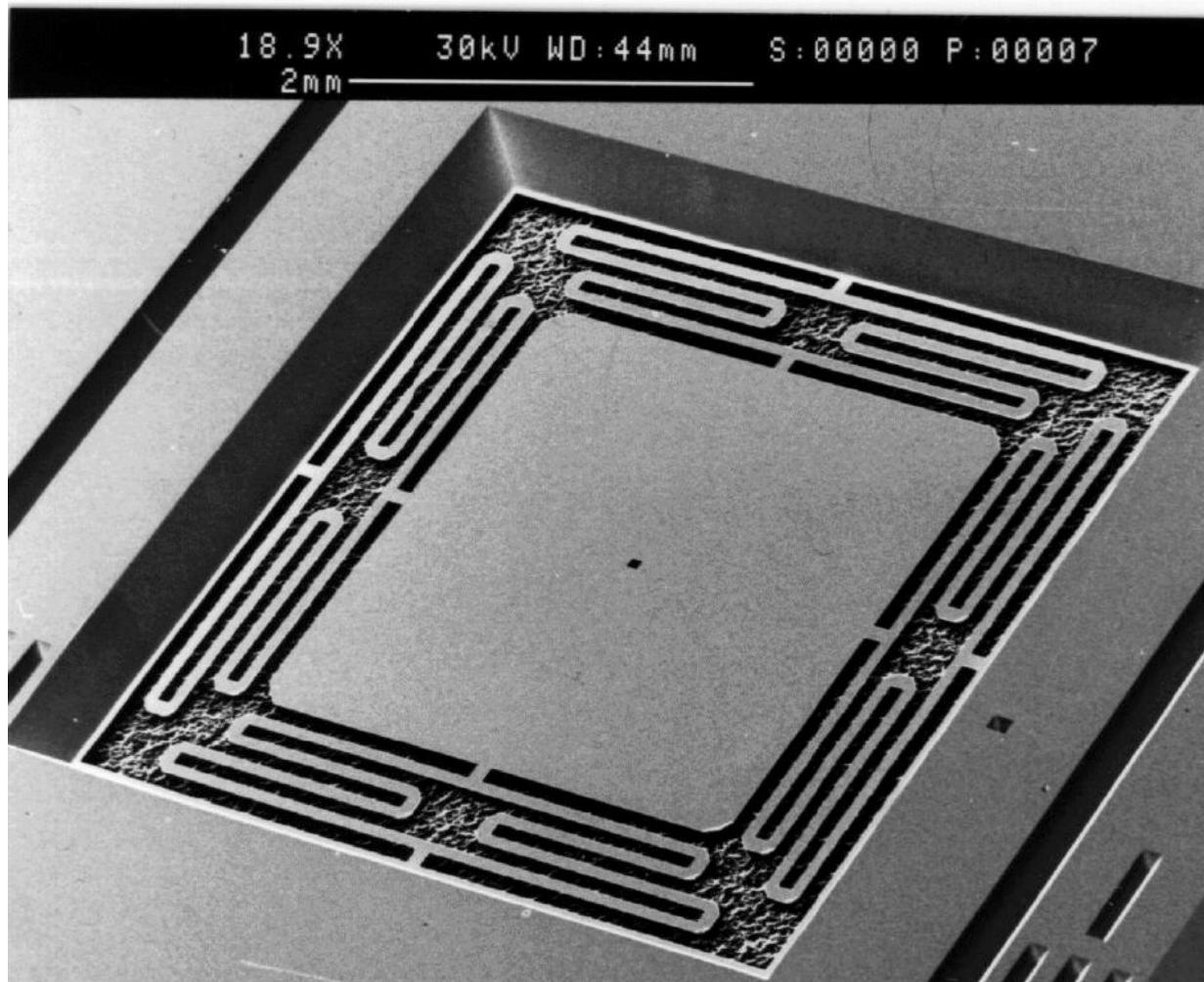
Application I: Embedded Spectrometer

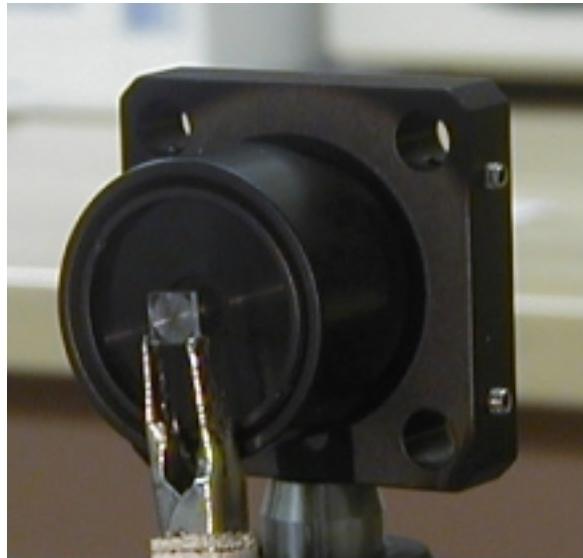


Application I: Scanner Development

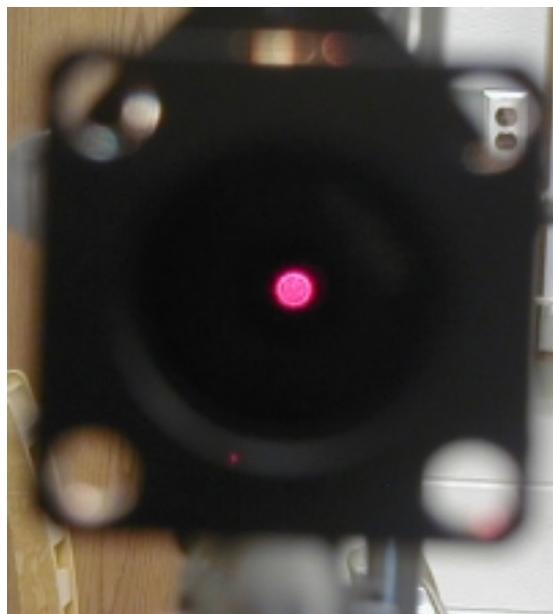
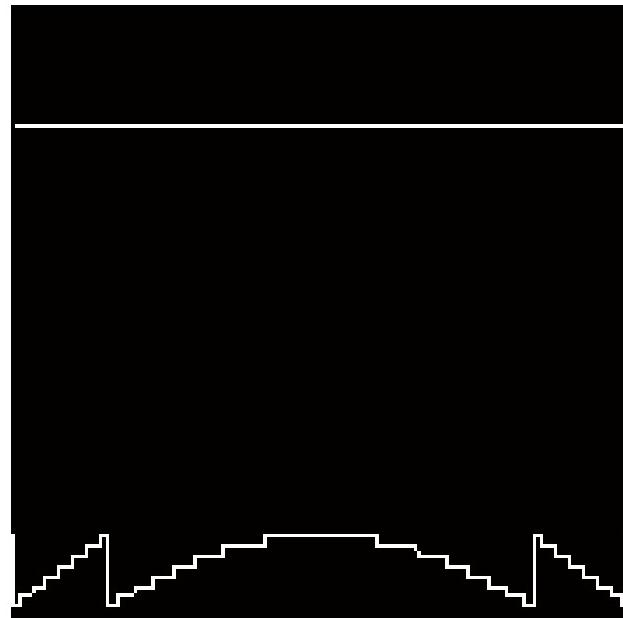


Collaboration with Chemnitz University of Technology, Germany

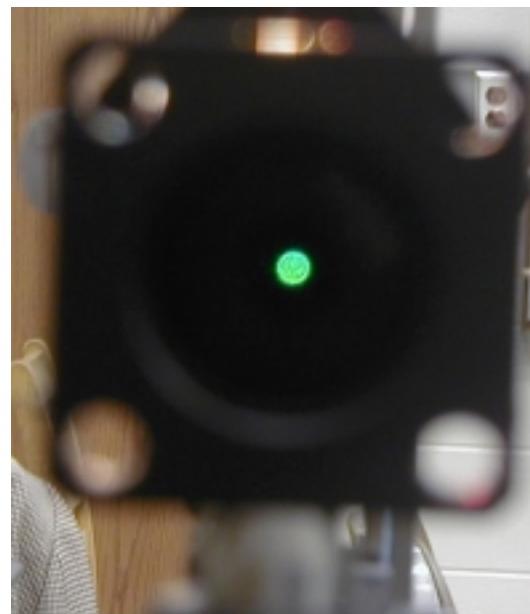




Spectrometer setup, $D = 5\text{mm}$, $f = 5\text{mm}$



7.86mm



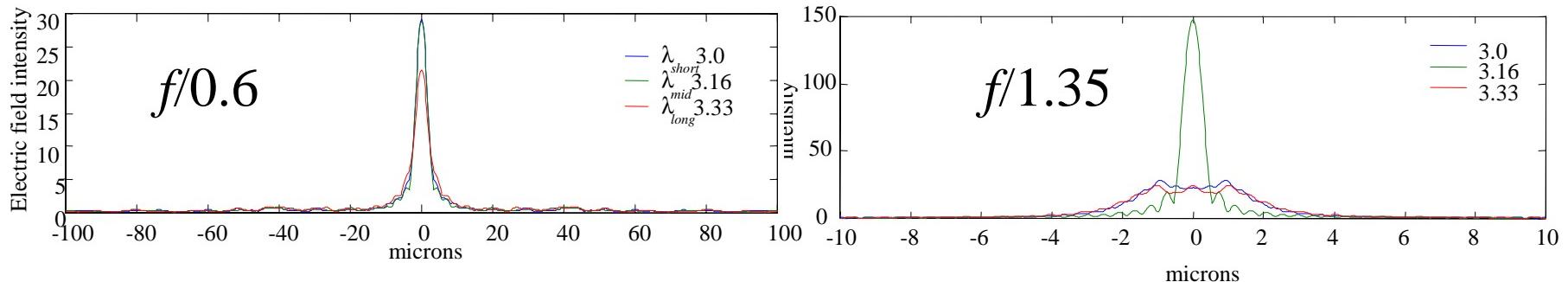
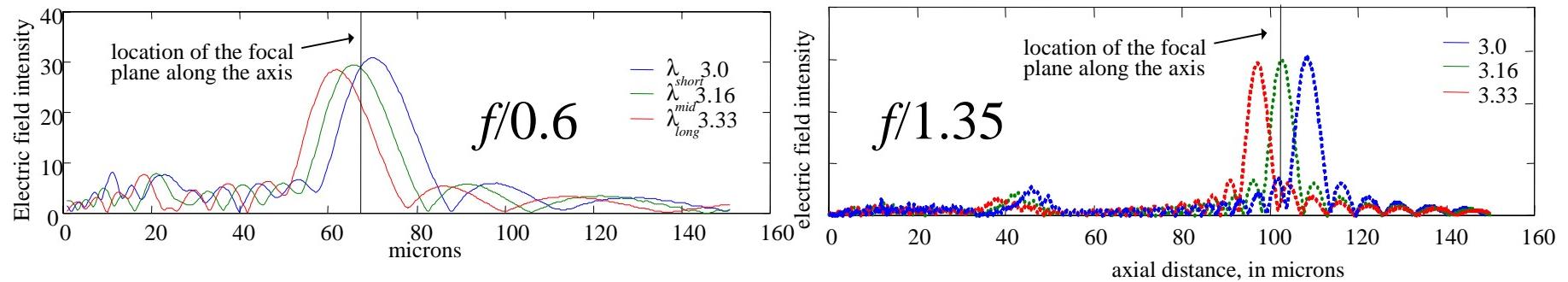
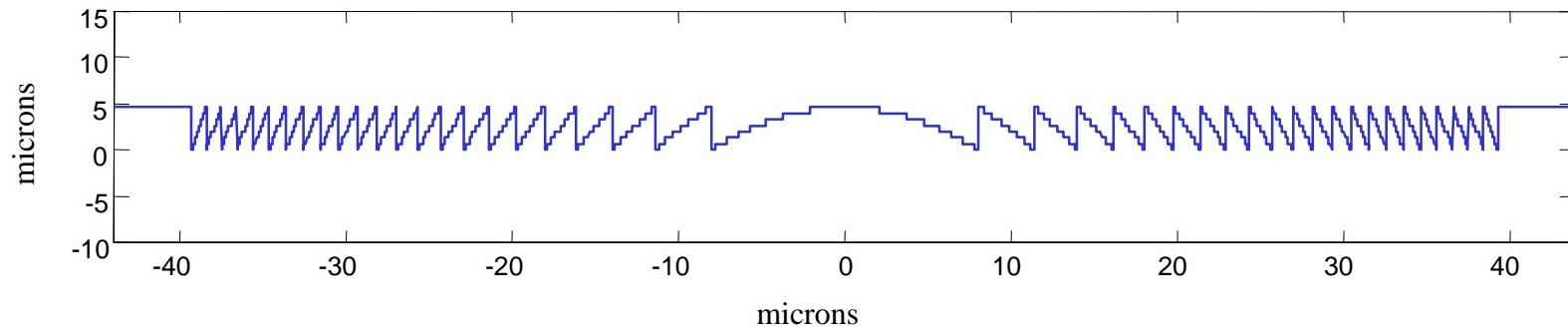
9.8mm



11.41mm

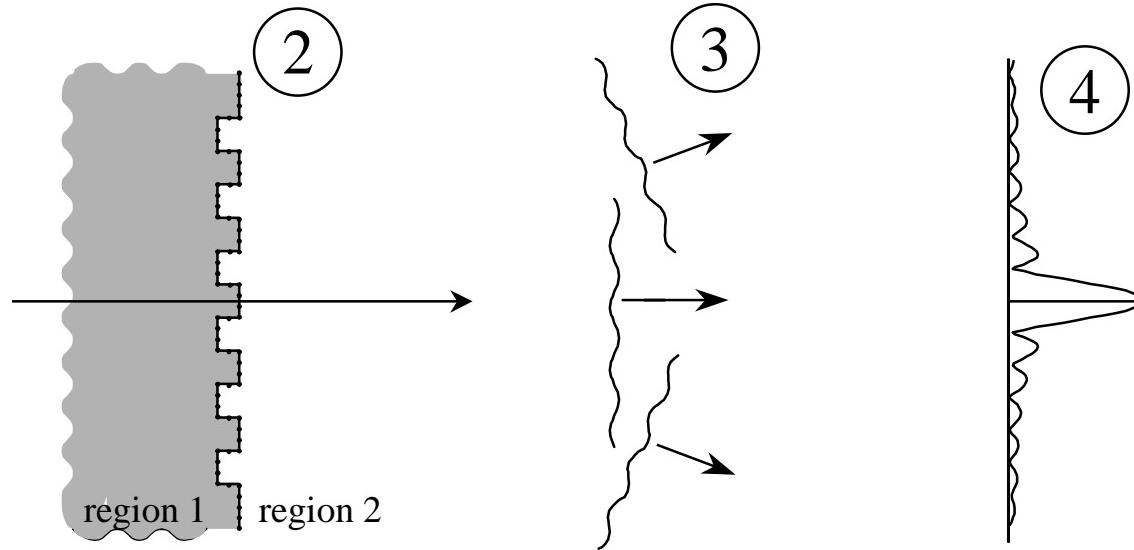


Application I: Lens Design





Electromagnetic-Based DOE Optimization

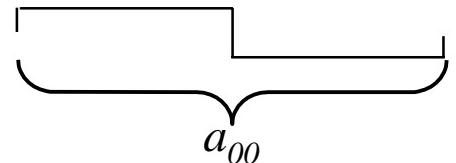


- Repeat
- 1. initial guess
 - 2. use rigorous electromagnetic model to analyze DOE
 - 3. evaluate performance
 - 4. optimize performance metric

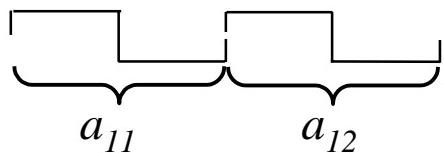


Wavelet-Based Optimization Method

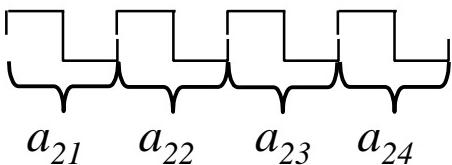
Wavelet Decomposition Process



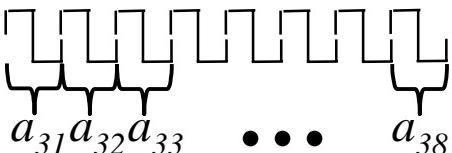
Zeroth order Haar Wavelet, $a_{00}\psi(x)$



First order Haar Wavelets, $a_{1m}\psi(2x - m)$

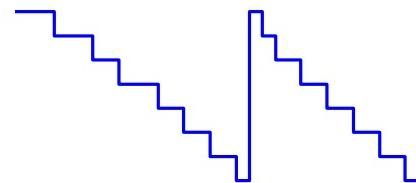
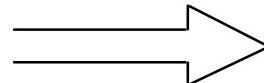


Second order Haar Wavelets, $a_{2m}\psi(2^2 x - m)$



Third order Haar Wavelets, $a_{3m}\psi(2^3 x - m)$

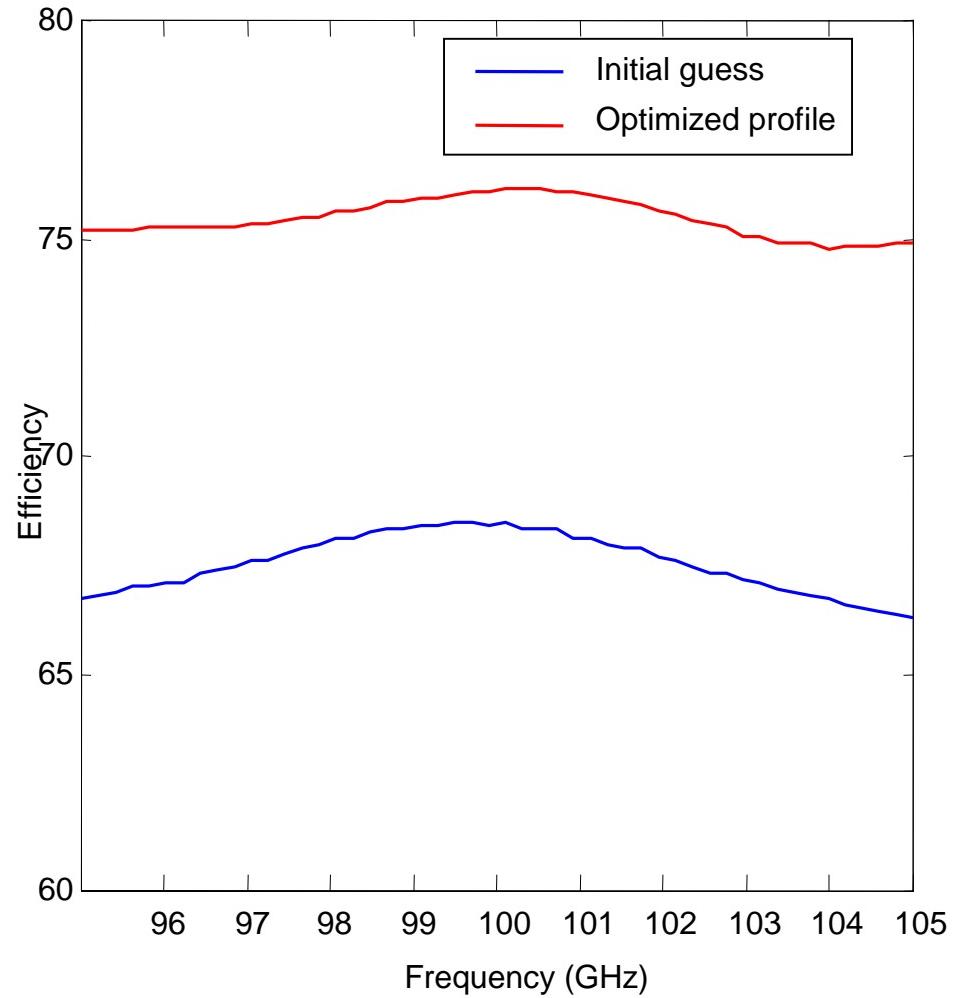
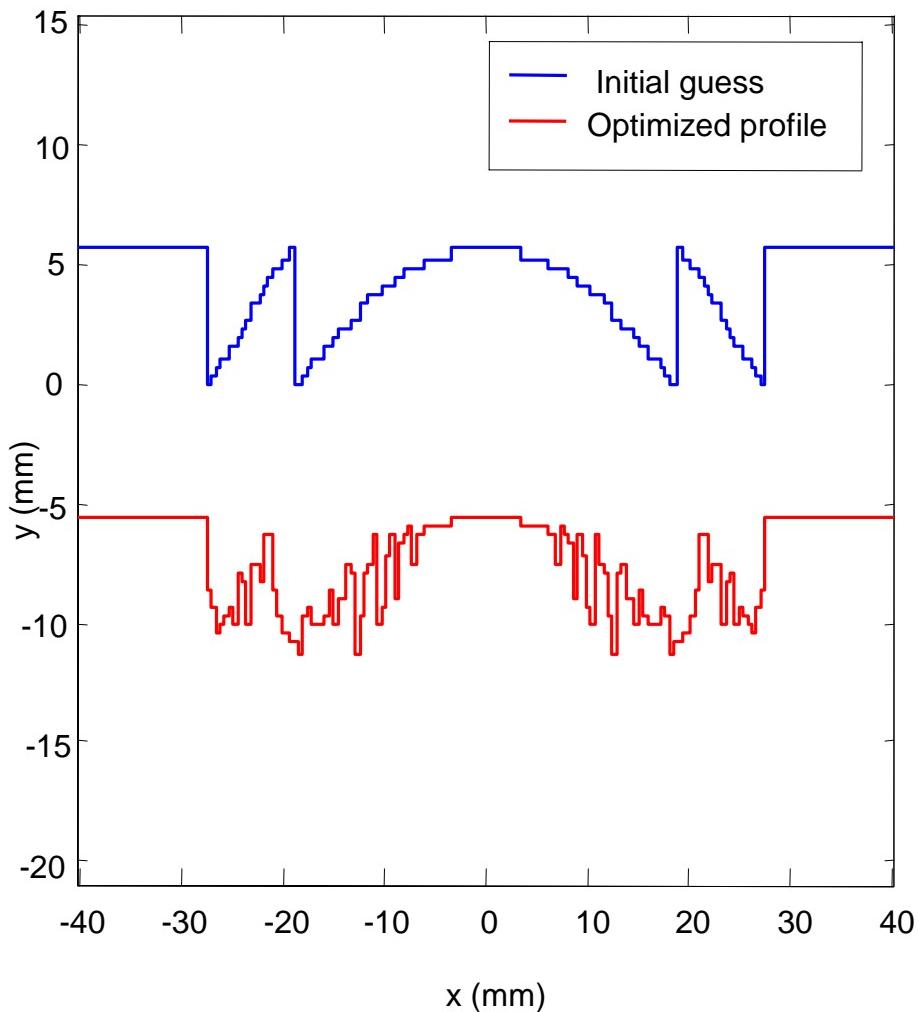
$$\sum_{n,m} a_{n,m} \psi(2^n x - m)$$



Diffractive Profile



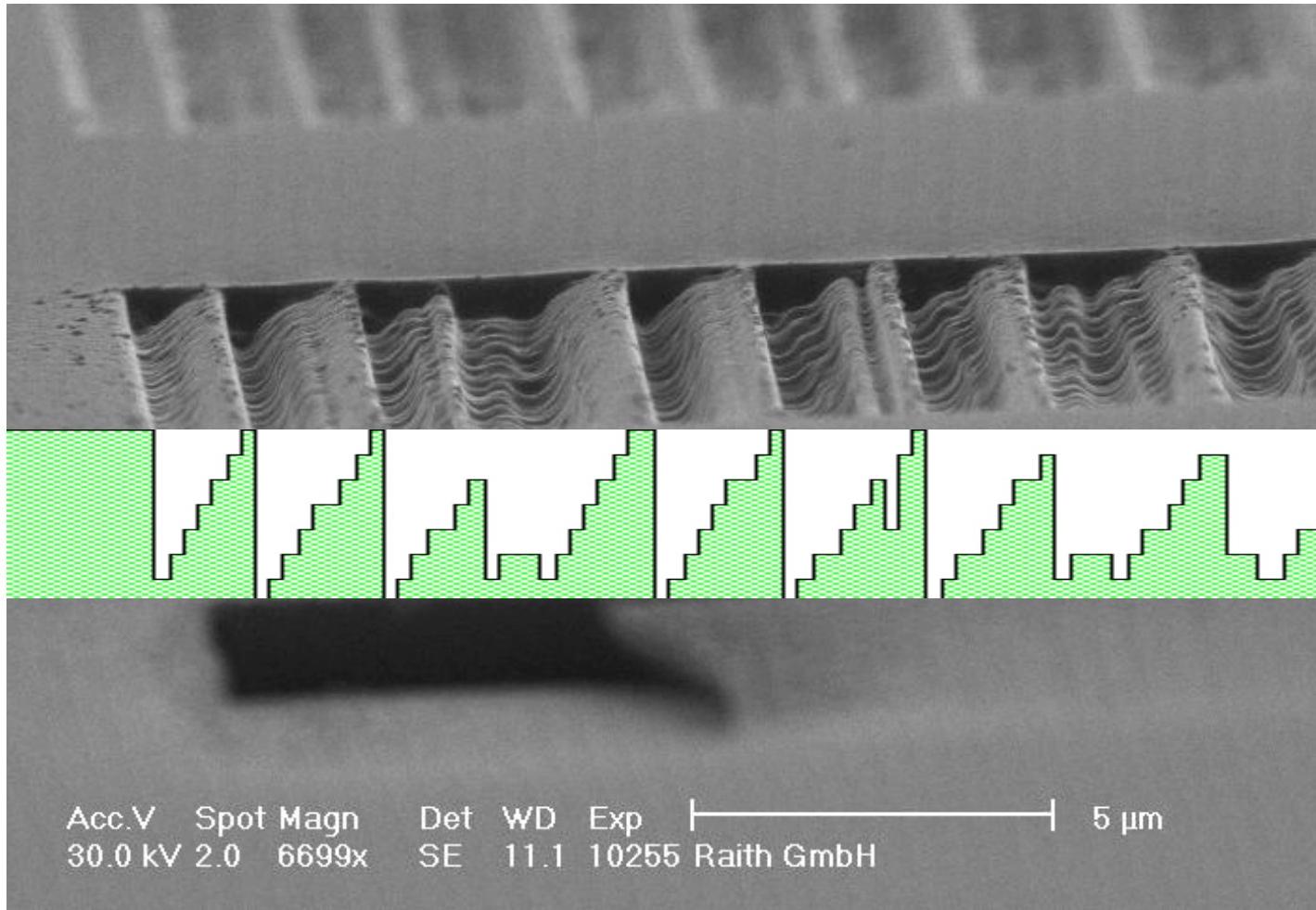
Profile and Efficiency Improvements





Fabrication of Grayscale Mesoscopic DOEs

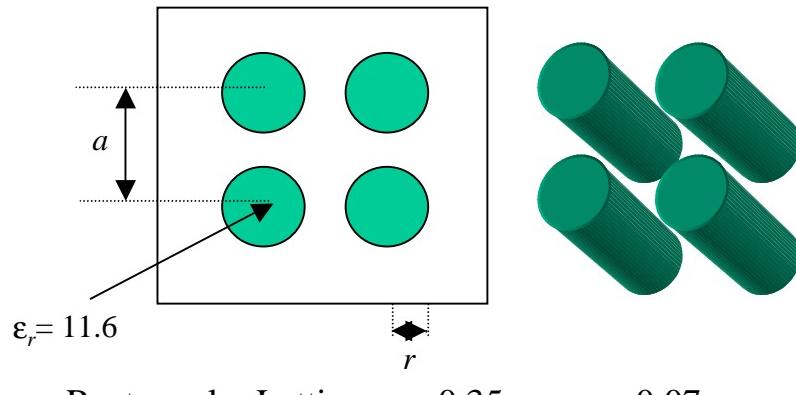
Outer zones of an 8-level EM optimized DOE



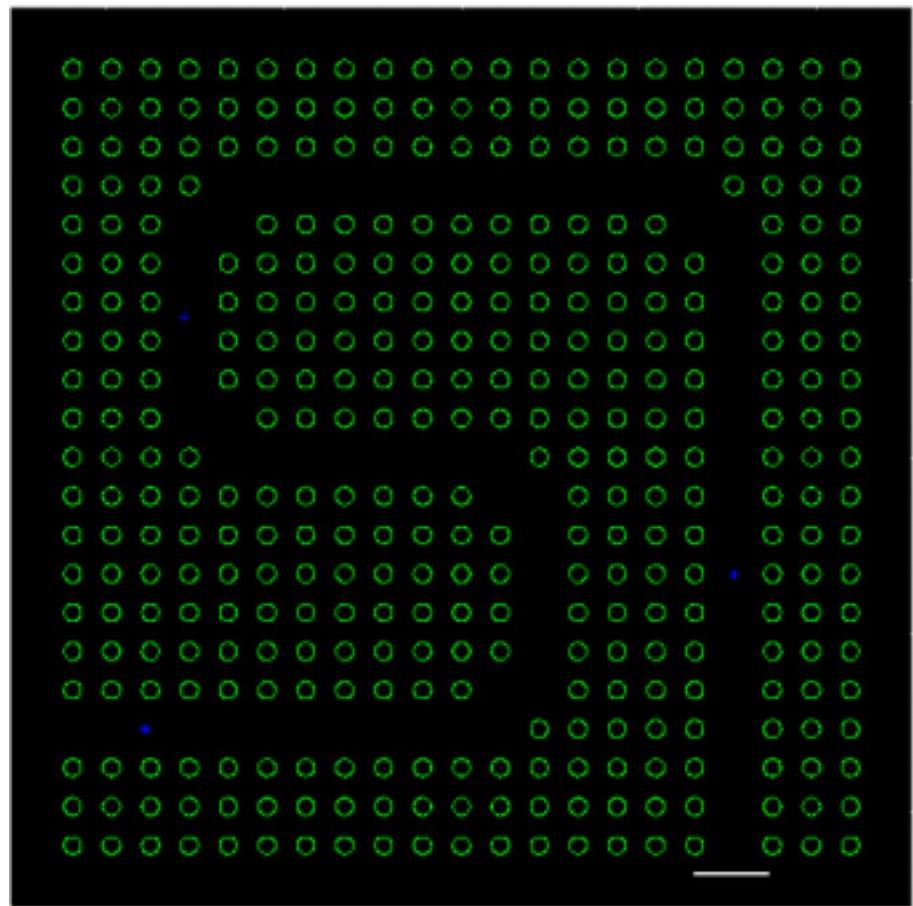
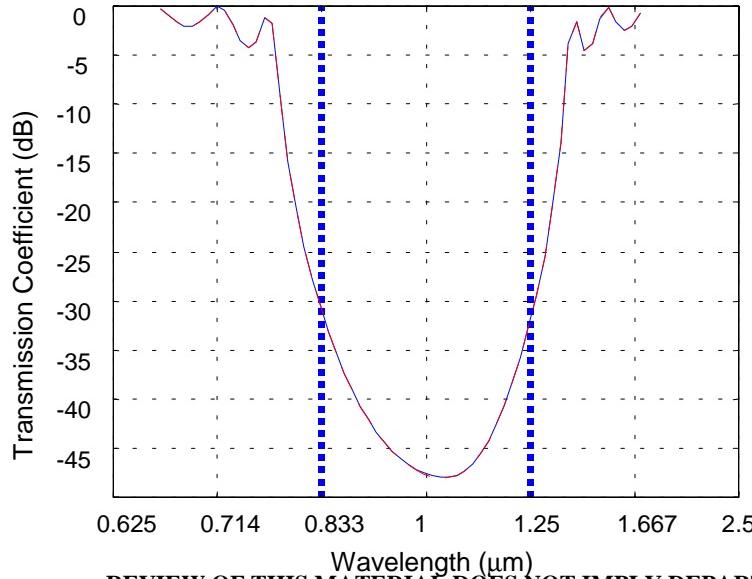


Application II: Photonic Band Gap Devices

- PBG's guide light based on the scattering properties created by tailoring the surface profile.
- They have a strong spectral dependence, which can be exploited in design.

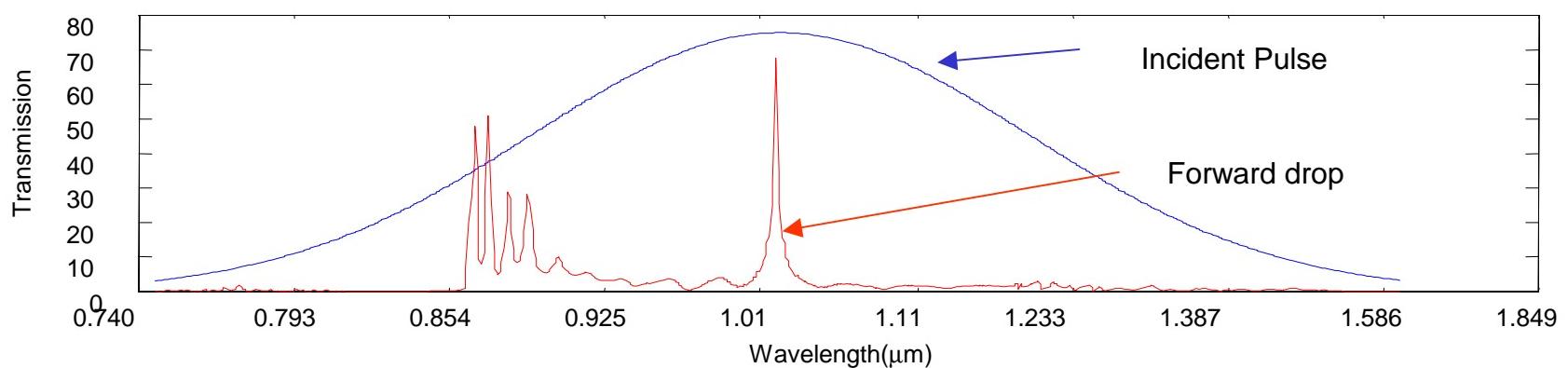
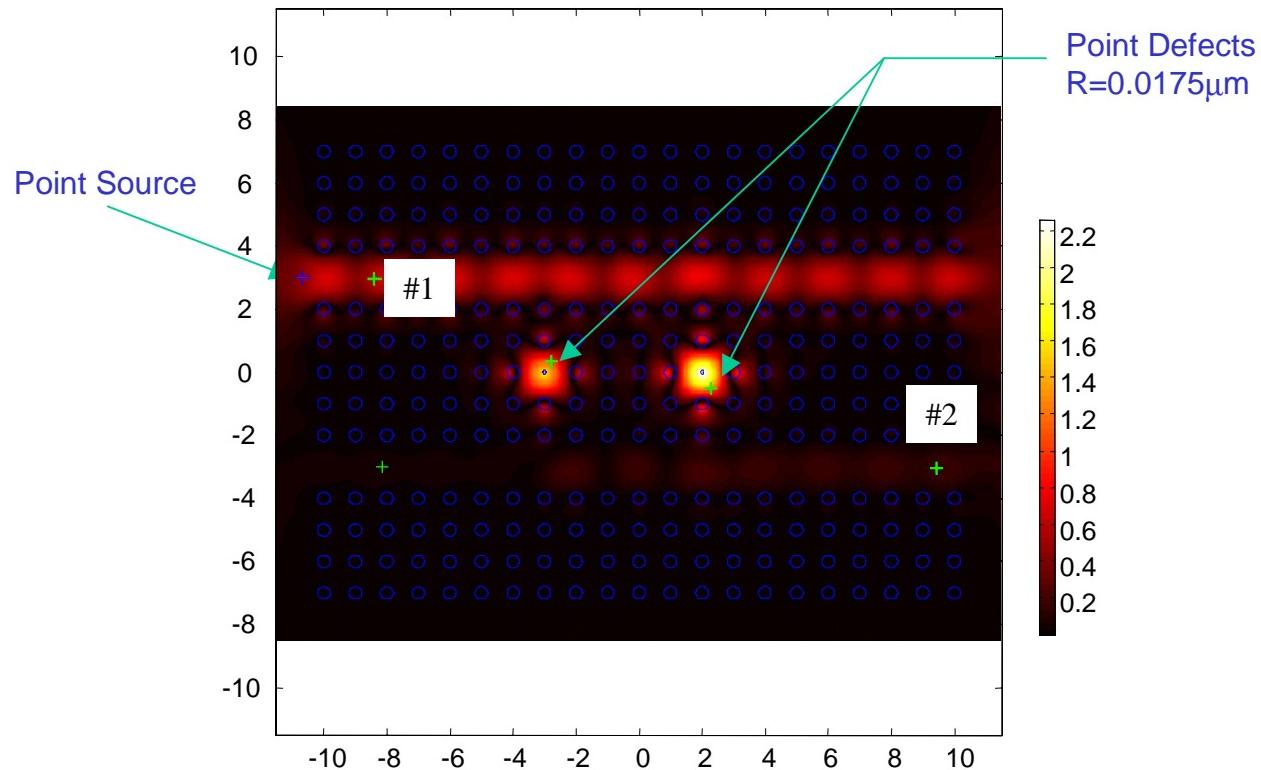


Rectangular Lattice: $a = 0.35 \mu\text{m}$, $r = 0.07 \mu\text{m}$



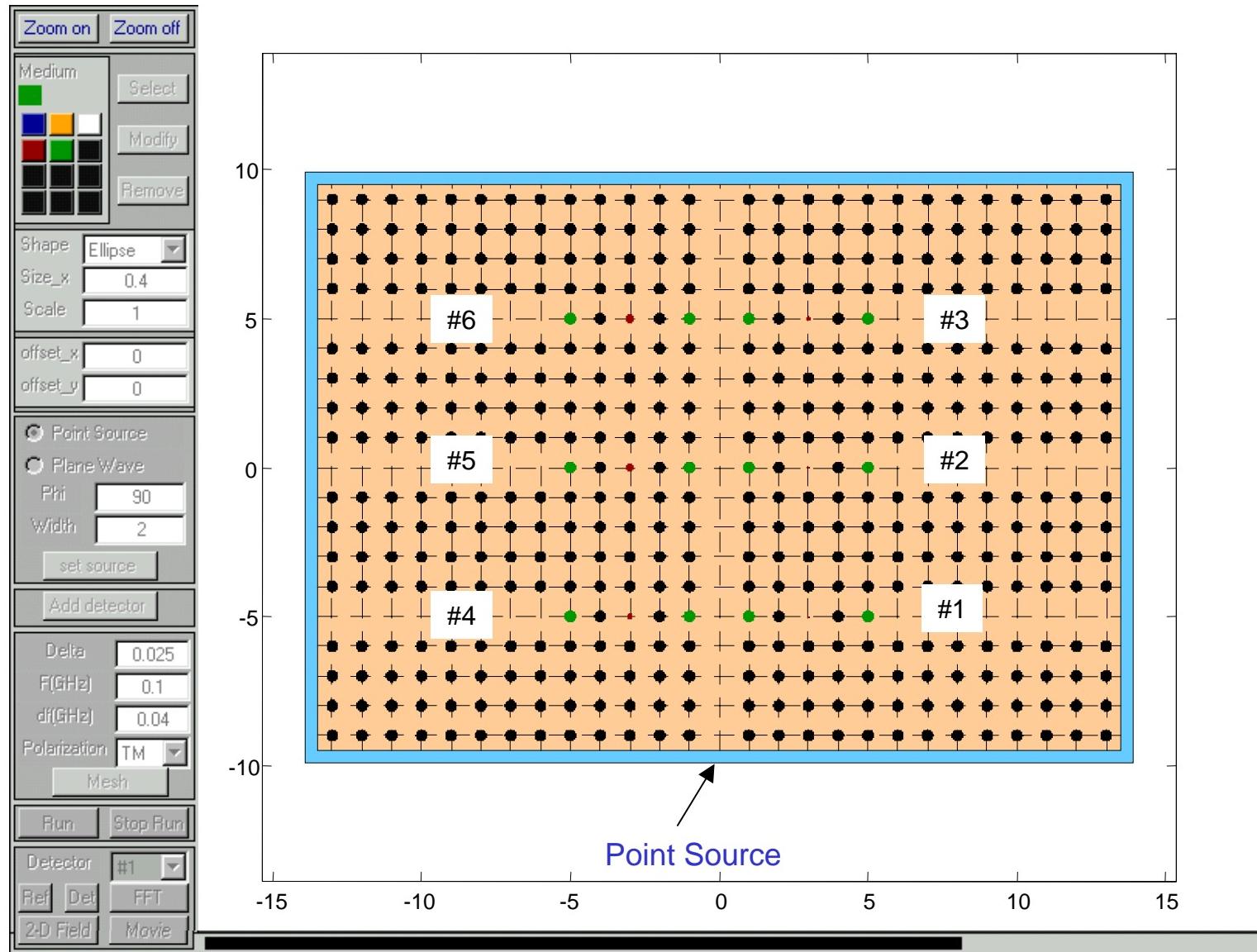


WDM Filtering using Two Cavities



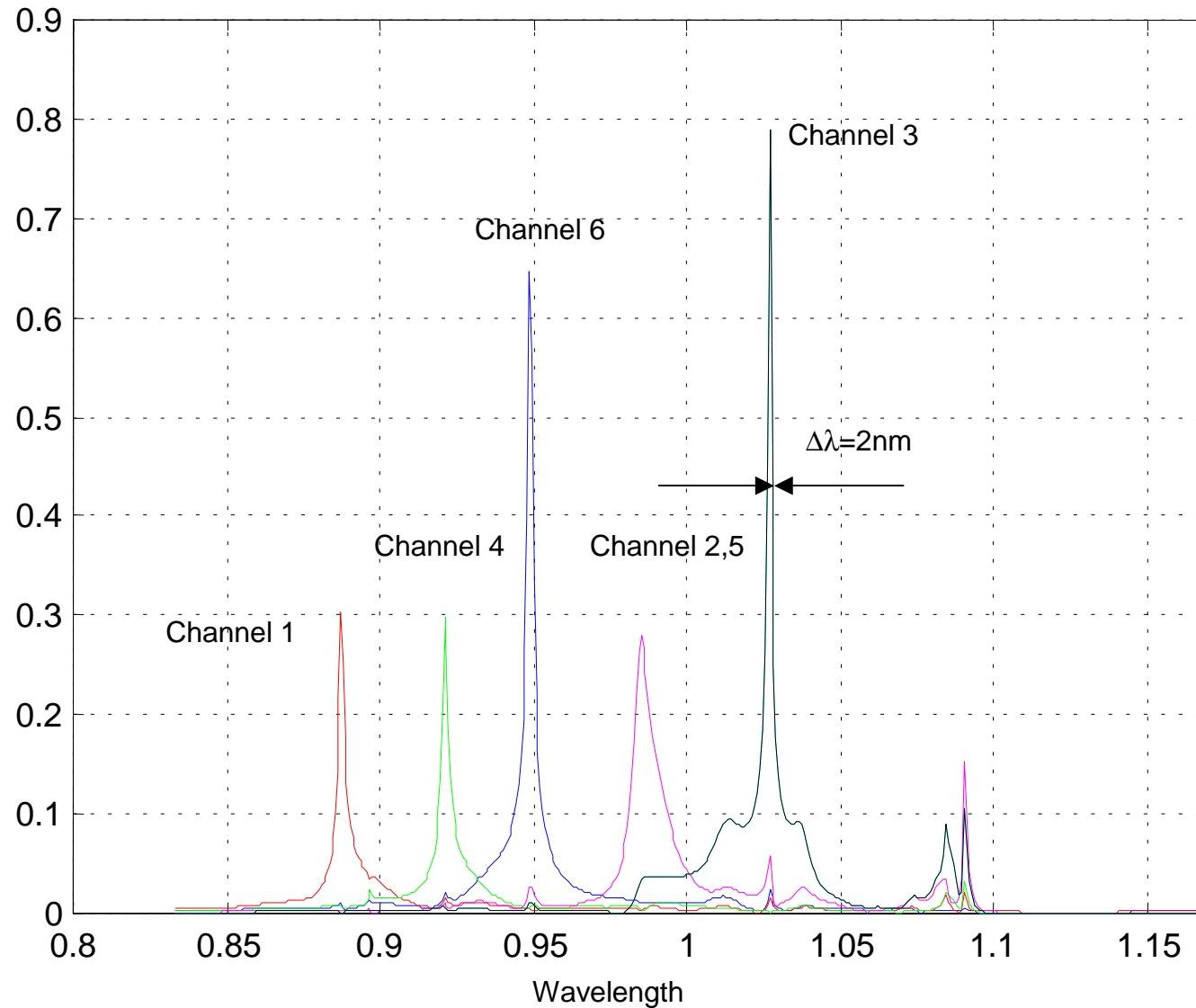


6 Channel WDM Filtering using Single Cavity Filters



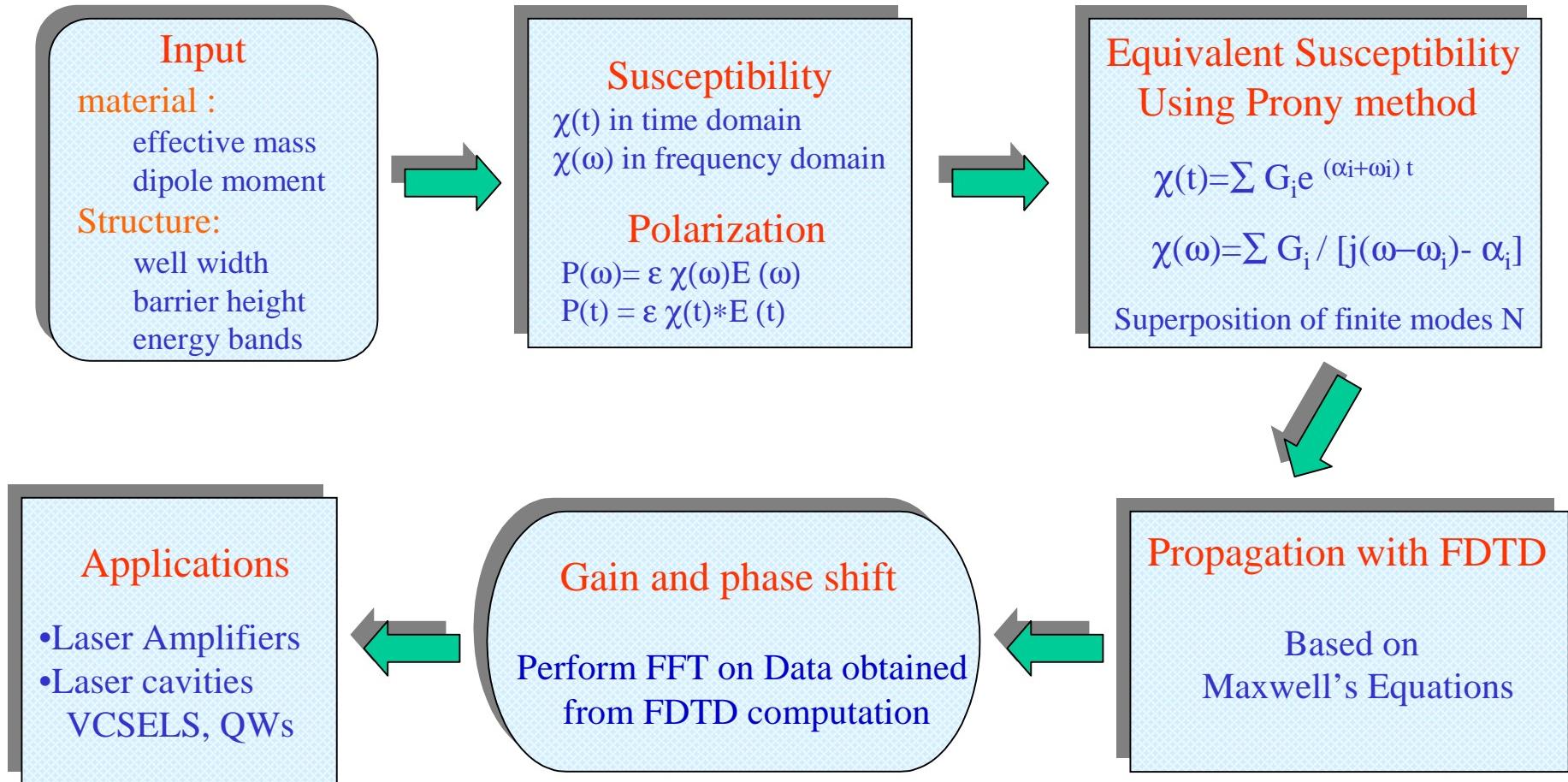


6 Channel WDM Filtering using Single Cavity Filters



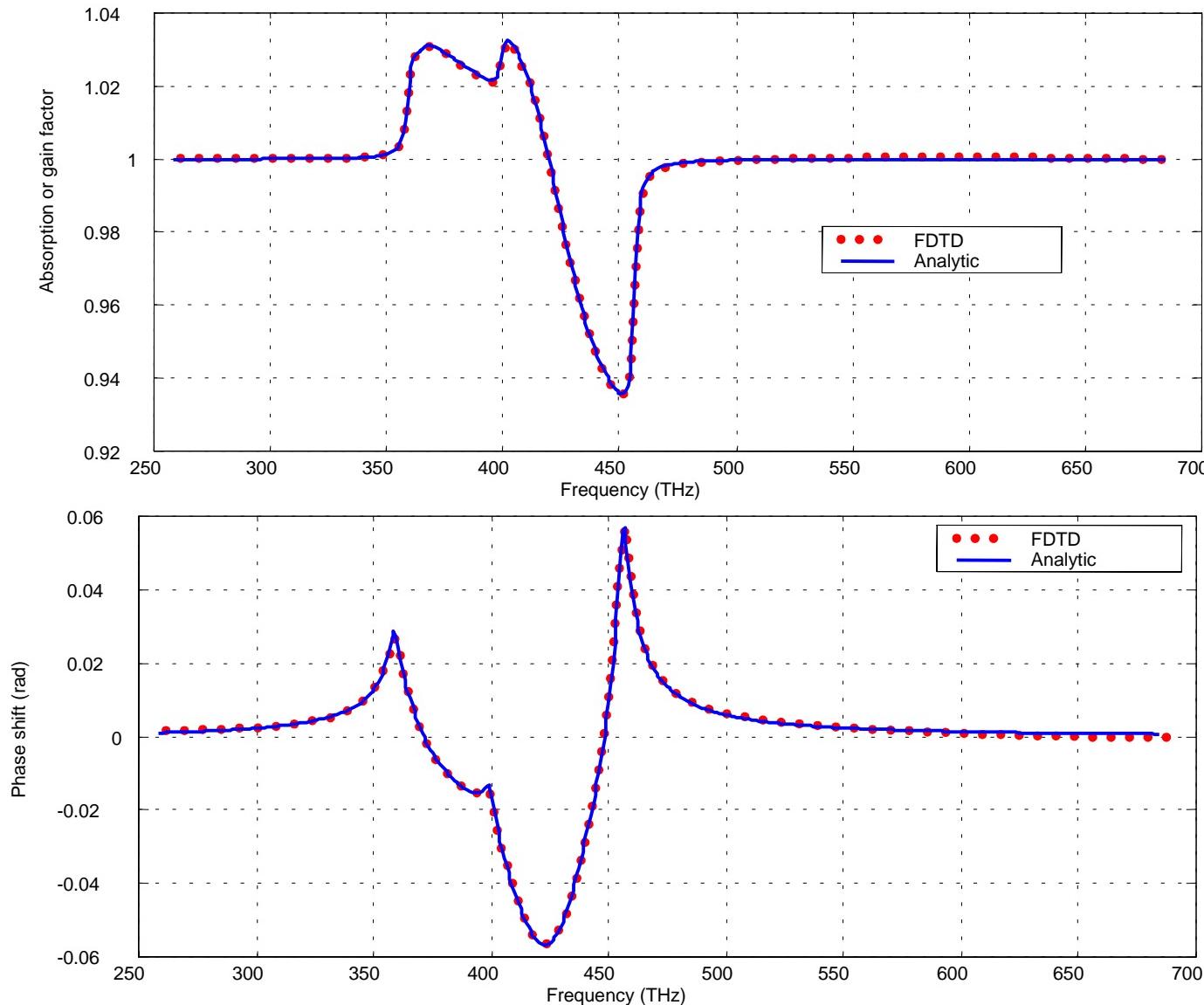


Parameterization Method for Semiconductor Amplifier





FDTD Results: $N = 12\text{e}18/\text{cm}^{-1}$





Semiconductor Gain Modeling in FDTD

GaAs :

Injected carrier: $N=9e24/m^3$

Dephasing time: $T_2=0.1\text{ps}$

Central frequency: $f=3.52 \cdot 10^{14}\text{Hz}$

$$A = -2.0896e+029$$

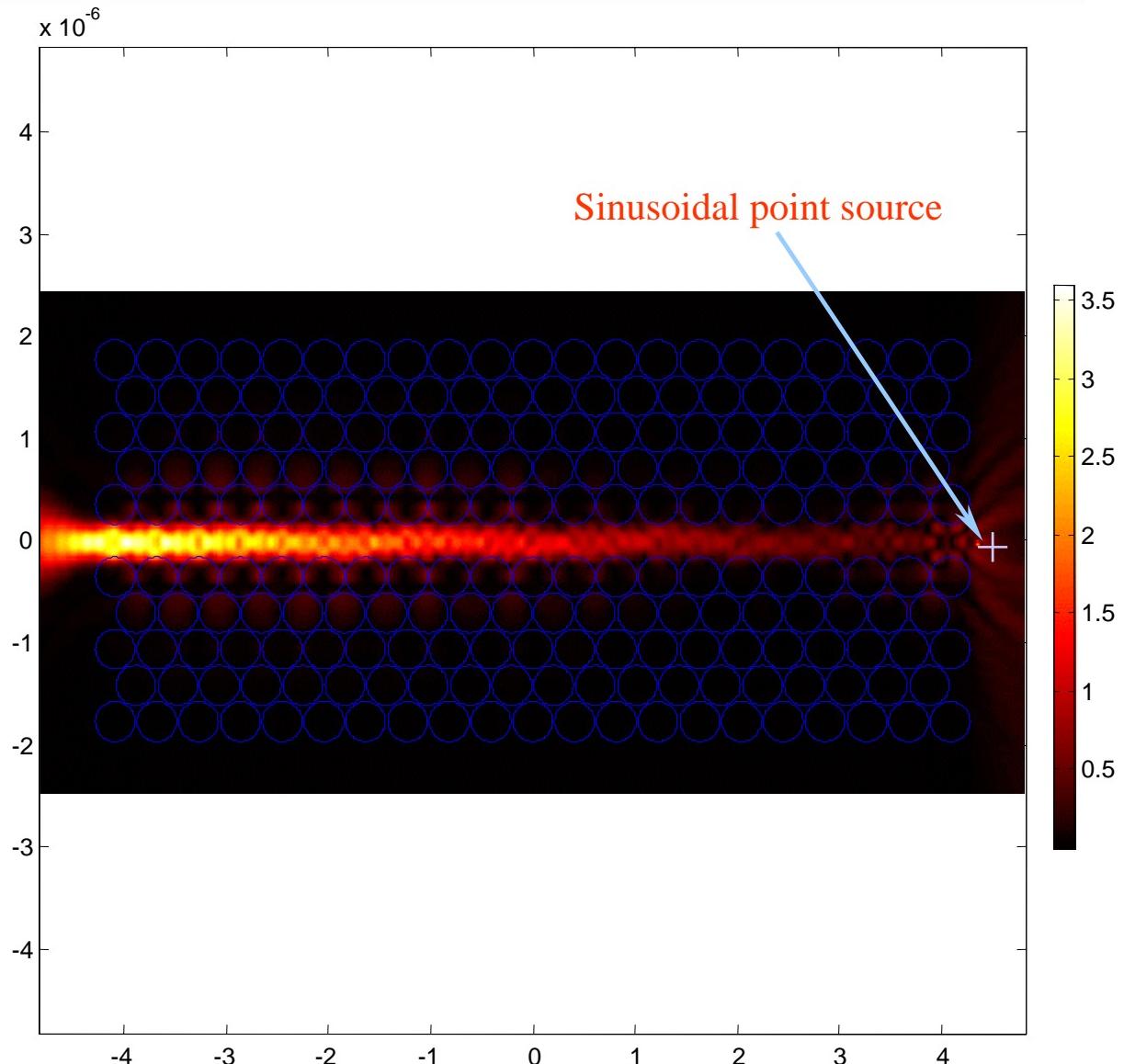
$$B = -3.6279e+043$$

$$\omega_0 = 2.4125e+015$$

$$\omega_t = 1.7361e+014$$

Equivalent conductivity

$$\sigma = (j \omega A + B) / (\omega_0^2 - 2j\omega_0\omega - \omega^2)$$





Summary

- Discussed the electromagnetic analysis and design of diffractive lenses and photonic band gap devices.
- Presented two applications for WDM
 - Embedded spectrometer
 - Photonic band gap filtering
- Introduced Wavelet based multiresolution optimization of diffractive lenses.
- Showed $f/\#$ dependence chromatic dispersion and its effect on spectral filtering.
- Channel drop filters based on an array of single cavity photonic band gap channels.